

[illegible]

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NER *Rafael Jacobs*

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APPLN. SERIAL NO.
09/679,297

APPLICANT(S)
Paul Nicolas MURET and Hui Sok MOON

FILING DATE
October 4, 2000

GROUP
2152

US PATENT DOCUMENTS

[illegible]

U.S. PATENT APPLICATION PUBLICATIONS

| | *PATENT APPLN. PUB. NO. | *PUB. DATE | *APPLICANT | CLASS | SUBCLASS | |
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U.S. PATENT APPLICATIONS

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| | *APPLN. NO. | *FILING DATE | *INVENTOR | CLASS | SUBCLASS | |
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FOREIGN PATENT DOCUMENTS

| EXAMINER'S INITIALS | PATENT NO. | DATE | COUNTRY | CLASS | SUBCLASS | Translation | |
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OTHER ART (Including Author, Title, Date, Pertinent Pages, Publisher, Place of Publication, Etc.)

EXAMINER

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